

CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8)			
Applicant(s): Young-Hoon Park		Docket No. YPL-0017	
Serial No. 09/848,577	Filing Date 5-3-2001	Examiner Moore, Karla A.	Group Art Unit 1763
Invention: REACTOR FOR DEPOSITING THIN FILM ON WAFER		RECEIVED CENTRAL FAX CENTER JAN 06 2004	
OFFICIAL			
<p>I hereby certify that this <u>Amendment Transmittal Letter (1 page), Amendment (12 pages) and Limited Recognition Under 37 C.F.R. Section 10.9-(b)-(1-page)</u> <small>(Identify type of correspondence)</small></p> <p>is being facsimile transmitted to the United States Patent and Trademark Office (Fax. No. <u>703-872-9306</u>)</p> <p>on <u>January 6, 2004</u> <small>(Date)</small></p>			
<p style="text-align: center;">Tammie Lanthier <small>(Typed or Printed Name of Person Signing Certificate)</small></p> <p style="text-align: center;"> <small>(Signature)</small></p>			
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Expires: August 4, 2004



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